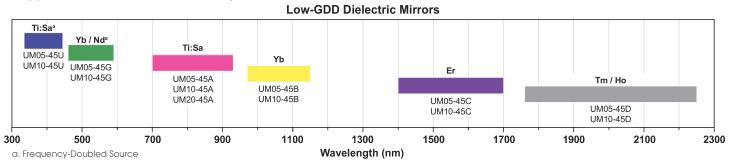
# **Low-Dispersion Optics**

#### Dielectric Mirrors with Low GDD

Our Low Group-Delay-Dispersion (GDD) Mirrors are optimized for low dispersion and high reflectance when used with Ti:Sapphire (Ti:Sa), Ytterbium (Yb), Neodymium (Nd), Eribium (Er), Thulium (Tm), or Holmium (Ho) lasers.

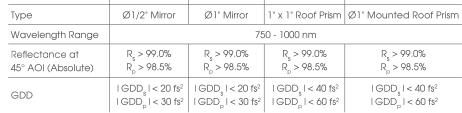


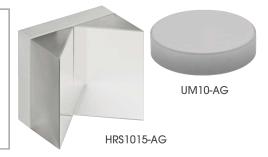
The colored bars represent our selection of low-GDD dielectric mirror coatings available from stock. Each coating is designed to work with a specific laser type, listed above the bar, while the mirrors specified for that wavelength range are indicated by the item #s below the bar. More information is available at www.thorlabs.com.

## Optics with Ultrafast-Enhanced Silver Coating

Mirrors coated with an Ultrafast-Enhanced Silver Coating offer a slightly lower reflectance over a much wider wavelength range than dielectric mirrors, making them a great choice when working with low energy lasers.

-Specif	icatio	ons ——			
Item #		UM05-AG	UM10-AG	HR\$1015-AG	HR1015-AG
Туре		Ø1/2" Mirror	Ø1" Mirror	1" x 1" Roof Prism	Ø1" Mounted Roof Prism
Wavelengt	h Range		75	50 - 1000 nm	
Reflectance	e at	R <sub>s</sub> > 99.0%			





## **Chirped Mirrors**

Our UMC05-15FS and UMC10-15FS mirrors are designed specifically to correct for GDD introduced by fused silica optics in a system. The DCMP175 Chirped Mirror Set compensates for GDD from a complex optical system such as a high-NA microscope objective. Spacifications



Item #	UMC05-15FS	UMC10-15FS	DCMP175	
Size	Ø1/2"	Ø1"	53.0 mm x 12.0 mm (Each, Set of 2)	
Wavelength Range	650 - 1	700 - 1000 nm		
Reflectance <sup>a</sup>	R <sub>abs</sub> > 99.5% at 10° AOI	R <sub>abs</sub> > 99.5% at 10° AOI	R <sub>avg</sub> > 99% at 8° AC	
GDD per Reflection at 800 nm	-54 fs² (-1.5 mm of Fused Silica)	-54 fs² (-1.5 mm of Fused Silica)	-175 fs <sup>2</sup>	

## **Controlled-GDD Beamsplitters**

Controlled-GDD beamsplitters can split p-polarized light in 20:80, 50:50, 80:20, or 90:10 split ratios with a known dispersion delay.



Specifications ——	UFBS2080	HEDGEGEG	UFBS8020	UEDCOO10		
irem #	UFB52080	UFBS5050	UFB58U2U	UFBS9010		
Reflectance/Transmission at 45° AOI	$R_{obs} = 20 \pm 2\%,$ $T_{obs} = 80 \pm 2\%$	$R_{obs} = 50 \pm 5\%,$ $T_{obs} = 50 \pm 5\%$	$R_{abs} = 80 \pm 5\%,$ $T_{abs} = 20 \pm 5\%$	$R_{abs} = 90 \pm 2\%,$ $T_{abs} = 10 \pm 2\%$		
Wavelength Range	600 - 1500 nm					
GDD in Reflection	0.2 mm of Fused Silica	0.7 mm of Fused Silica	2 mm of Fused Silica	-		
Infrasil® Window for Balancing GDDa	N/A	UDP05 or UDP10	N/A	N/A		

a. Infrasil windows will not fully balance dispersion for beamsplitters with split ratios other than 50:50. Thicker uncoated fused silica windows may be used instead